

**Application Data Sheet****Application Information**

Application Type::	Regular
Subject Matter::	Utility
CD-ROM or CD-R:	None
Title::	METHOD FOR FORMING SILICON EPITAXIAL LAYER
Attorney Docket Number::	117904
Total Drawing Sheets::	2
Small Entity::	Yes

**Applicant Information**

Applicant Authority type::	Inventor
Primary Citizenship Country::	Korea
Status::	Full Capacity
Given Name::	Tae Wan
Family Name::	LEE
City of Residence::	Seoul
Country of Residence::	Rep. of Korea

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Applicant Authority type::	Inventor
Primary Citizenship Country::	Korea
Status::	Full Capacity
Given Name::	Kyu Jin
Family Name::	CHOI
City of Residence::	Kyunggi-do
Country of Residence::	Rep. of Korea

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Applicant Authority type::	Inventor
Primary Citizenship Country::	Korea
Status::	Full Capacity
Given Name::	Jung Hoon
Family Name::	SUN
City of Residence::	Kyunggi-do

Country of Residence::	Rep. of Korea
Applicant Authority type::	Inventor
Primary Citizenship Country::	Korea
Status::	Full Capacity
Given Name::	Sung Jin
Family Name::	WHOANG
City of Residence::	Kyunggi-do
Country of Residence::	Rep. of Korea
Applicant Authority type::	Inventor
Primary Citizenship Country::	Korea
Status::	Full Capacity
Given Name::	Bok Won
Family Name::	CHO
City of Residence::	Kyunggi-do
Country of Residence::	Rep. of Korea

### Correspondence Information

Correspondence Customer Number:: 25944

Foreign Priority Information			
Country::	Application Number::	Filing Date::	Priority Claimed::
Korea	2002-75765	12/02/2002	Yes
Assignee Information			
Assignee Name::	JUSUNG ENGINEERING CO., LTD.		
Street of mailing address::	49 NEUNGPYEONG-RI, OPO-MYEON		
City of mailing address::	KWANGJU-GUN		
State or Province of mailing address::	KYUNGGI-DO		
Country of mailing address::	REP. OF KOREA		
Postal or Zip Code of mailing address::	464-890		